

**PATENT APPLICATION  
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of

Docket No: Q80708

Ryu OHTAGURO, et al.

Appln. No.: 10/808,540

Group Art Unit: 1756

Confirmation No.: 4872

Examiner: Stephen D. ROSASCO

Filed: March 25, 2004

For: SUBSTRATE FOR PHOTOMASK, PHOTOMASK BLANK AND PHOTOMASK  
**PETITION FOR EXTENSION OF TIME UNDER 37 C.F.R. § 1.136**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

Pursuant to 37 C.F.R. § 1.136, Applicant hereby petitions for an extension of time of three months, extending the time for responding to the Office Action of January 18, 2007 to July 18, 2007.

The statutory fee of \$1020.00 is being paid via the USPTO Electronic Filing System (EFS). The USPTO is also directed and authorized to charge all required fees, except for the Issue Fee and the Publication Fee, to Deposit Account No. 19-4880. Please also credit any overpayments to said Deposit Account.

Respectfully submitted,

/Ellen R. Smith/

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CUSTOMER NUMBER

Date: July 17, 2007